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Fabrication of oxide nanoparticles using oxidation of magnetic alloys in polyimide

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Oxide nanoparticles embedded in a polyimide (PI) matrix was fabricated by oxidizing a layer of $Ni_{80}Fe_{20}$ ($Co_{80}Fe_{20}$) metal film sandwiched between two PI precursor layers. Oxide nanoparticles nucleated in the PI matrix as a by-product of the imidization process. The 3.5 nm-thick $Ni_{80}Fe_{20}$ film was converted into a mono-layer of NiO oxide particles whose average size was 4.5 nm in diameter. When the metal film thickness was above 3.5 nm, a continuous layer of the metal film was found with selectively oxidized regions along the grain boundary. Similar observation was previously made when the γ -Fe₂O₃ particles were produced using the same reaction [1,2]. In case of the $Co_{80}Fe_{20}$ thin film, the oxide particles were composed of Co_3O_4 with spinel structure. These Co_3O_4 particles were, however, rather irregularly shaped with a wide size distribution whereas the NiO nanoparticles had spherical shapes with much narrower size distribution. X-ray photoelectron spectroscopy of oxide nanoparticles showed that the particles had a varying degree of metallic residue, suggesting that these nanoparticles could have metallic cores, surrounded by an oxide layer. Comparing with the γ -Fe₂O₃ particles produced using the same procedure, relatively larger amount of metallic residue was detected from the NiO and Co_3O_4 particles, which explains the higher magnetic moment measured from the NiO and Co_3O_4 particles.

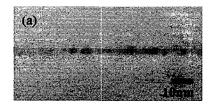




Fig 1. Cross-sectioal TEM images of the nanoparticles: (a) NiO, (b) Co₃O₄

References

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- [2] Y. M. Chiang et al., Physical Ceramics (John Wiley & Sons, Inc., NewYork, 1997), p. 368.

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